



2822

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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Applicant : Jerome T. Chu, et al.
Application No. : 09/964,227
Filed : September 26, 2001
Title : METHOD AND STRUCTURE FOR MODULAR, HIGHLY
LINEAR MOS CAPACITORS USING NITROGEN
IMPLANTATION
Grp./Div. : 2822
Examiner : M. Lewis
Docket No. : 42022/MJM/A717

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RESPONSE TO RESTRICTION REQUIREMENT

Assistant Commissioner for Patents
Washington, D.C. 20231

Post Office Box 7068
Pasadena, CA 91109-7068
September 25, 2002

Commissioner:

In response to the Office action (Restriction Requirement) dated August 27, 2002, applicants acknowledge the Examiner's requirement of restriction in the above-identified application and hereby elect Group II claims (claims 1-19) drawn to the method of forming MOS structure, classified in class 438, subclass 190, for the purposes of further prosecuting this patent application. This election is made without traverse.

In view of such election, applicants respectfully request that claims 1-19 be examined on the merits.

Respectfully submitted,
CHRISTIE, PARKER & HALE, LLP

By [Signature]
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MJM/dlf

DLF PAS462814.1-9/24/02 9:26 AM